

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1900	(photo\$resist\$4 OR resist\$4) NEAR20 (organic\$4 OR polymer\$4) NEAR20 (residue\$4 OR by\$1product\$4 OR scum\$4)	US-PGPUB; USPAT	OR	OFF	2005/11/14 18:01
L2	396	L1 AND (anti\$1reflecti\$4 OR BARC or ARC)	US-PGPUB; USPAT	OR	OFF	2005/11/14 18:02
L3	103	L2 AND poly\$1silicon\$4	US-PGPUB; USPAT	OR	OFF	2005/11/14 18:01
L4	6397	((216/41,49,51,74,75,79) or (134/1.2) or (438/706,714,719, 722-725)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/11/14 18:01
L6	32	L3 AND L4	US-PGPUB; USPAT	OR	OFF	2005/11/14 18:01
L7	717	(photo\$resist\$4 OR resist\$4) NEAR20 (organic\$4 OR polymer\$4) NEAR20 (residue\$4 OR by\$1product\$4 OR scum\$4)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 18:01
L8	11	L7 AND (anti\$1reflecti\$4 OR BARC or ARC)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 18:02